Polyfluoroalkyl Derivatives of Silicon. Part XIV.¹ Reaction of Trichlorosilane with 1,3,3,3-Tetrafluoropropene and 2-Chloro-1,3,3,3-tetrafluoropropene

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Photochemical reaction of trichlorosilane with 1,3,3,3-tetrafluoropropene gives trichloro(2-fluoro-1-trifluoromethyl)silane and trichloro(1.3.3,3-tetrafluoropropyl)silane (ratio 37:13), together with telomeric material. Similarly 2-chloro-1,3,3,3-tetrafluoropropene affords a mixture of trichloro(2-chloro-1,3,3,3-tetrafluoropropyl)silane and the reduced compound trichloro(1,3,3,3-tetrafluoropropyl)silane (ratio 7:3) in high yield. Treatment of trichloro(2-chloro-1.3.3.3-tetrafluoropropyl)silane with quinoline yields mainly cis- and trans-trichloro(1.3.3.3tetrafluoropropenyl)silane and a lesser amount of cis- and trans-trichloro(2-chloro-3,3,3-trifluoropropenyl)silane. This olefin mixture when fluorinated with antimony trifluoride gives a mixture of the trifluorosilyl analogues which is stable to 350 °C in vacuo.

As part of a further study of photochemical reactions of silanes with fluoro-olefins 1-5 the addition reactions of trichlorosilane with 1,3,3,3-tetrafluoropropene, (I), and 2-chloro-1,3,3,3-tetrafluoropropene, (II), have been investigated.

RESULTS AND DISCUSSION

1,3,3,3-Tetrafluoropropene, (I).-The olefin, prepared by reaction of trifluoroiodomethane with vinyl fluoride and dehydroiodination of the resulting 1:1 adducts,⁶ was obtained as a mixture of (I) and 2,3,3,3-tetrafluoropropene, (III), in the ratio 9:1 [equation (1)]. Photochemical reaction of this olefin mixture with excess of

$$CF_{3}I + CH_{2}:CHF \longrightarrow CF_{3} \cdot CH_{2} \cdot CHFI + CF_{3} \cdot CHF \cdot CH_{2}I$$

$$\downarrow^{KOH} \qquad \downarrow^{KOH} \qquad (1)$$

$$CF_{3} \cdot CH:CHF \qquad CF_{3} \cdot CF:CH_{2}$$

$$(I) \qquad (III)$$

trichlorosilane gave unchanged olefin (63% recovered), a mixture of the 1:1 adducts trichloro(2-fluoro-1-trifluoromethylethyl)silane, (IV) (46%), and (trichloro-1,3,3,3-tetrafluoropropyl)silane, (V) (16%), formed from olefin (I) [equation (2)], trichloro(2,3,3,3-tetrafluoropropyl)silane, (VI) (7%), formed from olefin (III) [equation (3)], and telomeric material.

(I)
$$\xrightarrow{\text{HSiCl}_{3}} CF_{3} \cdot CH(SiCl_{3}) \cdot CH_{2}F +$$

(IV) $CF_{3} \cdot CH_{2} \cdot CHF \cdot SiCl_{3}$ (2)
(V)
(III) $\xrightarrow{\text{HSiCl}_{3}} CF_{3} \cdot CHF \cdot CH_{2} \cdot SiCl_{3}$ (3)
(VI)

¹ Part XIII, R. N. Haszeldine, C. R. Pool, and A. E. Tipping, J.C.S. Dalton, 1975, 2177.

² R. N. Haszeldine and R. J. Marklow, J. Chem. Soc., 1956, 962; A. M. Geyer and R. N. Haszeldine, *ibid.*, 1957 1038, 1925; R. N. Haszeldine and J. C. Young, *ibid.*, 1960, 4503; D. Cooper, R. N. Haszeldine, and M. J. Newlands, J. Chem. Soc. (A), 1967, 2098.

The 1:1 adducts were not separated, but they were identified from a molecular-weight determination on the mixture, g.l.c., and n.m.r. spectroscopy. The ¹⁹F n.m.r. spectrum of the major adduct (IV) showed the presence of a CF₃·CH grouping (d, J 10.3 Hz) and a CH₂F group (t, J 51.1 Hz). The spectra of adduct (V) showed the presence of a CHF group (J 54.1 Hz) which was not adjacent to the CF_3 group and those of adduct (VI) showed the presence of a CHF group adjacent to the CF_3 group [$J(CF_3-F)$ 12.7; $J(CF_3-H)$ 8.1 Hz]. Pure adduct (V) was also separated from the reaction of HSiCl₃ with olefin (II) (see later).

The ratio (37:13) of 1:1 adducts, (IV) and (V), cannot be regarded as quantitative because the adduct yield was only 62% and telomeric material of unknown composition was formed. However, on a qualitative basis, this ratio can be compared with that obtained previously for photochemical reaction of HSiCl₃ with hexafluoropropene which gave the 1:1 adducts CF_3 ·CF-(SiCl₃)·CHF₂ and CF₃·CHF·CF₂·SiCl₃ in the ratio 65: 35.⁵ Thus in both reactions predominant attack by the highly electrophilic trichlorosilyl radical takes place at the most sterically hindered internal vinylic carbon atoms. The adduct (VI) obtained via trichlorosilyl radical attack on the terminal CH₂ group of olefin (III) was the expected exclusive product since addition to the olefin CF3 CH: CH_2 is reported ³ to take place *via* exclusive attack on the terminal CH₂ group.

2-Chloro-1,3,3,3-tetrafluoropropene, (II).-Photochemical reaction of HSiCl₃ with olefin (II) (4:1 molar ratio) gave silicon tetrachloride (29%), (V) (29%), and the 1:1 adduct trichloro(2-chloro-1,3,3,3-tetrafluoropropyl)silane, (VII) (66%). The n.m.r. spectra of adduct

³ A. M. Geyer, R. N. Haszeldine, K. Leedham, and R. J.

Marklow, J. Chem. Soc., 1957, 4472.
⁴ W. I. Bevan and R. N. Haszeldine, unpublished work;
W. I. Bevan, R. N. Haszeldine, J. Middleton, and A. E. Tipping,

 J.C.S. Dalton, 1974, 2305.
 ⁵ C. J. Attridge, C. J. Bridge, D. Cooper, G. Cross, R. N. Haszeldine, M. J. Newlands, and A. E. Tipping, unpublished work.

⁶ R. Gregory, R. N. Haszeldine, and A. E. Tipping, J. Chem. Soc. (C), 1970, 1750.

(VII), although in agreement with the proposed structure, were complex, which indicates that adduct (VII) was formed [equation (4)] as a mixture of the two possible diastereoisomers. The reduced silane (V) is con-

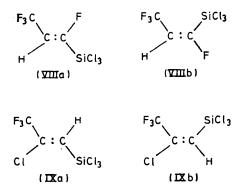
sidered to have been formed by reduction of adduct (VII) (equation (5)]. The possibility that (V) was formed by reduction of olefin (II) to (I), followed by addition of $HSiCl_3$ to the reduced olefin [equation (6)], was ruled out because $HSiCl_3$ reacts with (I) to afford a mixture of

$$CF_{3} \cdot CCl:CHF \xrightarrow{\cdot SiCl_{3}} CF_{3} \cdot \dot{C}:CHF \xrightarrow{HSiCl_{3}} (I) \quad (6)$$

adducts (IV) and (V) with the former predominating (see earlier).

Reaction of adduct (VII) with quinoline gave olefin (I) (trace), unchanged (VII) (26%), trichloro(*cis*-1,3,3,3-tetrafluoropropenyl)silane, (VIIIa) (29%), trichloro-(*trans*-1,3,3,3-tetrafluoropropenyl)silane, (VIIIb) (6%), trichloro(*cis*-2-chloro-3,3,3-trifluoropropenyl)silane,

(IXa) (7%), and trichloro(*trans*-2-chloro-3,3,3-trifluoro-propenyl)silane, (IXb) (2%). Olefins (VIIIa) and

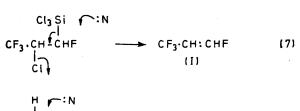


(VIIIb) were identified by comparison of their n.m.r. spectra with those of the olefins prepared by reaction of $HSiCl_3$ with tetrafluoropropyne.⁷ The major olefin (IX) isomer was assigned structure (IXa) on the basis of the observation in the n.m.r. spectra of coupling (1.6 Hz) between the CF_3 group and the proton; the other isomer showed no such coupling.

The products are considered to be formed by the elimination reactions (7)—(9). This result is in contrast

⁷ R. N. Haszeldine, C. R. Pool, and A. E. Tipping, J.C.S. Perkin I, 1974, 2293.

to the previous observation¹ that reaction of the silanes CH_2Cl ·CHF·SiCl₃ and CH_2F ·CHF·SiCl₃ with quinoline gave vinyl fluoride from exclusive nucleophilic attack by



$$\begin{array}{cccc} N: & \mathcal{H} & & \\ & & & \\ & & & \\ CF_3 \cdot CCI^2 CH \cdot SiCI_3 & \longrightarrow & CF_3 \cdot CCI : CH \cdot SiCI_3 & (9) \\ & & & & \\ & & & & \\ & & & \\ & & & & \\ & & & \\ & & & & \\ & & & & \\ & & & & \\ & & & & \\ & & & & \\ & & & & \\ & & & & \\ & & & & \\ & & & & \\ & & & & \\ & & & & \\ & & & & \\ & & & & \\ & & & & \\ & & & & \\$$

quinoline at silicon. The formation of the trichlorosilylsubstituted olefins (VIII) and (IX) in the present reaction is probably due to a combination of the bulk and strong electron-withdrawing effect of the trifluoromethyl group. The size of the CF₃ group could sterically hinder attack at silicon relative to attack at hydrogen and its -I effect renders the hydrogen atoms in the CHCl and CHF groups acidic and thus susceptible to attack by base. Dehydrochlorination of adduct (VII) to give (VIII) is, as expected on the basis of the relative C-Cl and C-F bond strengths, more favoured than dehydrofluorination to give (IX).

Fluorination of the mixture of olefins (VIII) and (IX) with antimony trifluoride gave a mixture (70%) of the corresponding trifluorosilyl compounds, CF₃·CH·CF·SiF₃ and CF₃·CCI·CH·SiF₃, which resisted pyrolysis at 350 °C (48 h) *in vacuo* and was almost quantitatively recovered (97%) unchanged. Traces of silicon tetra-fluoride and 3,3,3-trifluoropropyne were detected in the pyrolysis product which could have arisen by reaction (10) or (11). Since SiCl₄ was not detected the former mechanism is more likely.

Thus the α -fluoro-olefin CF₃·CH·CF·SiF₃ is thermally more stable than the α -chloro- and α -bromo-olefins CH₂·CCI·SiF₃ and CH₂·CBr·SiF₃ which decompose at *ca*. 280 °C. In contrast, (1-chloro-1-fluoroalkyl)trifluorosilanes, RCFCI·SiF₃,⁸ decompose at *ca*. 150 °C *via* nucleophilic attack of the α fluorine on silicon.

⁸ W. I. Bevan, R. N. Haszeldine, J. Middleton, and A. E. Tipping, J. Organometallic Chem., 1970, 23, C17; J.C.S. Dalton, 1975, 620.

EXPERIMENTAL

Techniques used were as described previously.⁴ ¹⁹F n.m.r. chemical shifts are relative to external trifluoroacetic acid. 2-Chloro-1,3,3,3-tetrafluoropropene, (II), was prepared by photochemical chlorination of 1,3,3,3-tetrafluoropropene, (I) (98%), followed by dehydrochlorination of the resulting dichloride with potassium hydroxide *in vacuo* (69%). Spectral details of compounds marked with an asterisk are in Supplementary Publication No. SUP 21471 (5 pp.).*

Photochemical Reaction of Trichlorosilane with a Mixture of (I) and 2,3,3,3-Tetrafluoropropene (III).—A mixture of (I) (12.0 g, 0.105 mol), (III) (1.19 g, 10.35 mmol), and HSiCl₃ (49.2 g, 0.36 mol), sealed in a silica ampoule (ca. 250 cm³) and irradiated at a distance of 15 cm from a Hanovia S500 u.v. lamp (15 d), gave (i) a mixture of unchanged olefin (8.3 g, 72.5 mmol, 63% recovered), (ii) unchanged HSiCl₃ (ca. 45 g, ca. 90% recovered), (iii) a mixture (7.35 g, 29.2 mmol, 69%) (Found: M 245. Calc. for C₃H₃Cl₃F₄Si: M 250.5), b.p. 64 °C, shown by g.l.c. (4 m Silicone at 75 °C) to contain three components (ratio 64:25:11) identified by n.m.r. spectroscopy as trichloro(2-fluoro-1-trifluoromethylethyl)silane, (IV) * (4.92 g, 19.6 mmol, 46%), trichloro-(1,3,3,3-tetrafluoropropyl)silane, (V) * (1.69 g, 6.62 mmol, 16%), and trichloro(2,3,3,3-tetrafluoropropyl)silane, (VI) * (0.74 g, 2.9 mmol, 7%), and (iv) a teleomeric residue (ca. 1.5 g) which was not examined further.

Attempts to separate the components of the 1:1 adduct fraction by fractional distillation through a spinning-band column (50 cm) were unsuccessful.

Reaction of HSiCl₃ with (II).—A mixture of HSiCl₃ (40.0 g, 0.293 mol) and (II) (11.2 g, 75.5 mmol), treated as in the previous experiment (300 h) and the products distilled through a fractionating column (30 cm), gave (i) HSiCl₃ (ca. 30 g, ca. 75% recovered), b.p. 32—33 °C, (ii) SiCl₄ (3.7 g, 21.8 mmol, 29%), b.p. 65 °C, and (iii) a mixture (19.6 g, 72.0 mmol, 95%), b.p. 50—60 °C at 42 mmHg,† of (V) (5.41 g, 21.7 mmol, 29%) and trichloro(2-chloro-1,3,3,3-

* For details see Notice to Authors No. 7, *J.C.S. Dalton*, 1974, Index issue (items less than 10 pp. are supplied as full-size copies). $\uparrow 1 \text{ mmHg} \approx 13.6 \times 9.8 \text{ Pa.}$ tetrafluoropropyl)silane, (VII) (14.2 g, 50.3 mmol, 66%). This mixture was redistilled through a spinning-band column (50 cm) at reduced pressure (44 mmHg) to afford trichloro(1,3,3,3-tetrafluoropropyl)silane, (V) * (5.25 g, 21.5 mmol, 29%) (Found: C, 14.1; H, 1.3. $C_3H_3Cl_3F_4Si$ requires C, 14.4; H, 1.2%), b.p. 52 °C at 44 mmHg, and trichloro(2-chloro-1,3,3,3-tetrafluoropropyl)silane, (VII) * (14.0 g, 49.4 mmol, 65%) (Found: C, 13.0; H, 0.7. $C_3H_2Cl_4F_4Si$ requires C, 12.7; H, 0.7%), b.p. 59 °C at 44 mmHg.

Reaction of (VII) with Quinoline.-Silane (VII) (4.2 g, 14.8 mmol) was added dropwise (30 min) to quinoline (4.0 g, 31.0 mmol) and the reaction mixture slowly warmed until an exothermic reaction started. The reaction was allowed to subside and the volatile products were separated to give (i) (I) (trace), (ii) unchanged silane (1.1 g, 3.9 mmol, 26%recovered), and (iii) a mixture (1.2 g, 4.8 mmol, 44%) (Found: M 250. Calc. for C₃HCl₃F₄Si: M 247.5), shown by g.l.c. (2 m dinonyl phthalate at 80 °C) and n.m.r. spectroscopy to contain four components (A)—(D) in the ratio 65:15:16:4. Components (A) and (B) were identified as trichloro(cis-1,3,3,3-tetrafluoropropenyl)silane (VIIIa) (0.78 g, 3.15 mmol, 29%) and trichloro(trans-1,3,3,3-tetrafluoropropenyl)silane, (VIIIb) (0.17 g, 0.67 mmol, 6%), respectively, by comparison of their ¹H and ¹⁹F n.m.r. spectra with those of authentic samples prepared by reaction of HSiCl₃ with tetrafluoropropyne.⁷ Components (C) and (D) were identified as the cis- and trans-isomers of trichloro(2chloro-3,3,3-trifluoropropenyl)silane, (IXa) and (IXb) * (0.25 g, 0.95 mmol, 9%).

Fluorination of a Mixture of (VIII) and (IX).—A mixture (0.5 g) of the olefins as prepared in the previous experiment (ratio 79:21), treated with a large excess (ca. 25 g) of SbF₃ containing SbF₅ (5% by weight) in vacuo at room temperature, gave a mixture (0.28 g, 70%) (Found: M 202. Calc. for C₃HF₇Si: M 198) of the corresponding trifluorosilanes.* This mixture (0.25 g), sealed in a Pyrex ampoule (ca. 60 cm³) and heated at 350 °C (48 h), gave (i) SiF₄ (trace), (ii) 3,3,3-trifluoropropyne (trace), and (iii) unchanged reactant (0.24 g, 97% recovered). Reaction at 240 °C (96 h) gave only unchanged reactant (100%).

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